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Boosting the performance of NO_2 gas sensors based on n–n type mesoporous $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires: *in situ* conducting probe atomic force microscopic elucidation of room temperature local electron transport†

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Herein, n–n type one dimensional $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires have been developed and their local electron transport properties during trace-level NO_2 gas sensing process have been probed at room-temperature using conducting probe atomic microscopy. Solvothermally synthesized 1D $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires have been characterized by various spectroscopic and microscopic techniques, which revealed the mesoporous structure indicating their enhanced sensing properties. The dangling bonds and fraction of metal ions to oxygen ions existing on the exposed crystal facets of the heterojunction nanowires have been visualized by employing crystallographic simulations with TEM analysis, which aided in forecasting the nature of surface adsorption of NO_2 gas species. *In situ* electrical characteristics and Scanning Spreading Resistance Microscopic (SSRM) imaging of single $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires revealed the local charge transport properties in n–n type $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires. Moreover, the $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires based sensor exhibited excellent sensitivity ($S = 274\%$), a fast response (4–6 s) and high selectivity towards trace-level concentration (500 ppb) of NO_2 gas under ambient conditions with low power consumption. Spatially resolved surface potential (SP) variations in $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires have been visualized using *in situ* Scanning Kelvin Probe Force Microscopy (SKPM) under NO_2 gas environment at room temperature, which was further correlated with its energy band structure. The work functions of the material evaluated by SKPM reveal considerable changes in the energy band structure owing to the local electron transport between ZnO and In_2O_3 at the heterojunctions upon exposure to NO_2 gas indicating the charge carrier recombination. A plausible mechanism has been proposed based on the experimental evidences. The results suggest that new insights into complex sensing mechanisms deduced from the present investigation on n–n type MOS based heterojunction nanowires under ambient conditions can pave the way for the novel design and development of affordable and superior real-time gas sensors.

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Introduction

Among various environmental pollutants released from industrial and automobile emissions, NO_2 is considered as the most dangerous air pollutant, as it leads to serious health hazards, and plays a major role in depletion of ozone (O_3) and acid rains.¹ Hence, it is highly essential to detect trace level NO_2 gas for environmental monitoring, human health and safety.² To address these serious concerns, incredible attempts have been

focused on advancement of NO_2 gas sensors based on metal-oxide semiconductors (MOSSs). ZnO ,³ Co_3O_4 ,⁴ SnO_2 ,⁵ WO_3 ,⁶ NiO ,⁷ In_2O_3 ,⁸ etc. have attracted tremendous interest in the gas sensor sector owing to their inexpensiveness, simple fabrication and superior sensing performance. Among various MOS materials, ZnO and In_2O_3 possess wider band gaps and have been realized for variety of applications, including gas sensors, solar cells,⁹ transparent conducting oxides¹⁰ etc. ZnO having a hexagonal crystal plane arrangement with a wurtzite structure along with a huge exciton binding energy of 60 meV is considered to be an ideal semiconductor for NO_2 gas sensors.^{11–13} However, though ZnO is being used in conventional MOS gas sensors, the issues associated with poor selectivity, high operating temperature and reliability hinder its practical applications. Similarly,

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n-type In_2O_3 (rhombohedral structure) has also gained significant attention towards NO_2 detection owing to its unique characteristics such as an extensive energy gap (2.5–3.75 eV), high electrical conductivity *etc.*¹⁴ However, pristine ZnO and In_2O_3 based sensors have found limited practical applicability due to their adverse effects in selectivity, higher operating temperature and poor response at trace level gas concentrations. Numerous studies have attempted to improve their sensing properties by modification with noble metals, surface alteration and shaping with p-n or n-n heterojunctions with alternate MOSSs. Mostly, binary oxide heterojunctions formed at the interfaces found to play an important role in augmenting sensing properties. The formation of n-n heterojunctions induces synergistic effects due to coupling of binary oxides with a minimal difference in work functions. Until now, n-n type binary oxide MOS nanohybrids, such as ZnO/SnO_2 ,¹⁵ WO_3/ZnO ,¹⁶ $\text{WO}_3/\text{In}_2\text{O}_3$,¹⁷ TiO_2/ZnO ,¹⁸ *etc.* have shown the significance of hetero-interfaces towards detection of noxious NO_2 . In this scenario, hierarchical hetero-nanostructures with a unique combination of ZnO and In_2O_3 could be expected to exhibit excellent NO_2 gas sensing properties with easy fabrication, long-term stability and enhanced sensitivity.^{3,19} However, the design of such heterojunction MOS based gas sensors demands precise understanding of the complex sensing mechanism for suitably deploying them for real time applications. Although there are a number of existing reports describing the sensing mechanism of pristine MOSSs, there is a serious lack of systematic investigations on heterojunction metal oxide materials owing to their interfacial structural complexity. Based on the literature, it can be ascertained that the development of high aspect ratio, one-dimensional MOS heterojunction nanostructures can greatly influence the sensing properties such as the gas response, sensitivity and selectivity.^{20,21} Advancements of n-n type MOS heterojunctions could be an appropriate strategy to extend the execution of gas sensors, but, comprehensive investigations pertaining to the complex sensing mechanisms are still under the infancy stage. Also, the crystallographic dependency of dissimilar heterojunction MOS materials on their gas sensor performance has not yet been thoroughly discussed.

Operando and *in situ* techniques, based on DRIFT,^{7,19} Raman spectroscopy,²² photoluminescence spectroscopy,²³ XPS,^{24,25} UV-DRS,²⁶ EPR,²⁷ *etc.* have been utilized to elucidate the sensing mechanism of pristine MOSSs towards different gases. Recently, Patsha *et. al.*, reported local electron transfer process and surface band bending during methane sensing by pristine GaN nanowires using *in situ* SKPM analysis.²⁸ Kaur *et. al.*, attempted to explore the charge transfer mechanism of a polypyrrole–tin oxide nanocomposite (PPy– SnO_2) nanowire based NH_3 sensor using *in situ* SKPM studies.²⁹ But, so far, no reports are available on exploration of complex sensing mechanism of MOS based heterojunction materials using *in situ*/operando studies.

Our previous report demonstrated the enhanced NO_2 sensing and electron transport properties of n-p type ultra-long $\text{ZnO}/\text{Bi}_2\text{O}_3$ heterojunction nanorods.³² Though the ultra-long ZnO based n-p type $\text{ZnO}/\text{Bi}_2\text{O}_3$ heterojunction nanorods showed superior NO_2 sensing performances, the high operating temperature limited their possible practical applications. With

this investigation, we have developed n-n type $\text{ZnO}/\text{In}_2\text{O}_3$ heterojunction nanowires, which can operate at reduced operating temperature with sustainable sensitivity. The surface activity of ZnO could be enhanced by coalescence of In_2O_3 nanoislands on the surface that can act as a lever of charge transfer during exposure of NO_2 gas and aided in the augmentation of sensing characteristics. So far, very few reports have attempted SKPM to demonstrate the sensing behaviour of nanomaterials.^{28–31} To the best of our knowledge, this is the first report on room-temperature local charge transport properties for unravelling the complex mechanism pertaining to NO_2 sensing properties of mesoporous n-n type $\text{ZnO}/\text{In}_2\text{O}_3$ heterojunction nanowires based on SKPM and SSRM. The NO_2 sensing properties of pristine ZnO nanowires and $\text{ZnO}/\text{In}_2\text{O}_3$ heterojunction nanowires were investigated towards trace level NO_2 gas, and $\text{ZnO}/\text{In}_2\text{O}_3$ heterojunction nanowires exhibited excellent sensitivity, improved selectivity and rapid response and recovery time at room temperature, indicating their potential usage in real time applications.

Experimental section

Materials used

Zinc chloride dihydrate ($\text{ZnCl}_2 \cdot 2\text{H}_2\text{O}$, 99.8%, Merck), indium acetate ($\text{In}(\text{CH}_3\text{COO})_3$, 99.99%, Sigma Aldrich), sodium dodecylbenzene sulfonate (SDS, 99.97%, Merck), sodium carbonate (Na_2CO_3 , 99.9%, Merck), ethylene glycol (EG, 99.8%, Merck), and ethanol ($\text{C}_2\text{H}_5\text{OH}$, 99%, Merck) were used without any further purification.

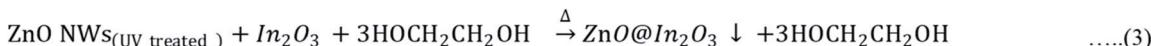
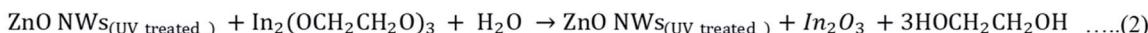
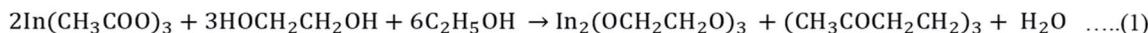
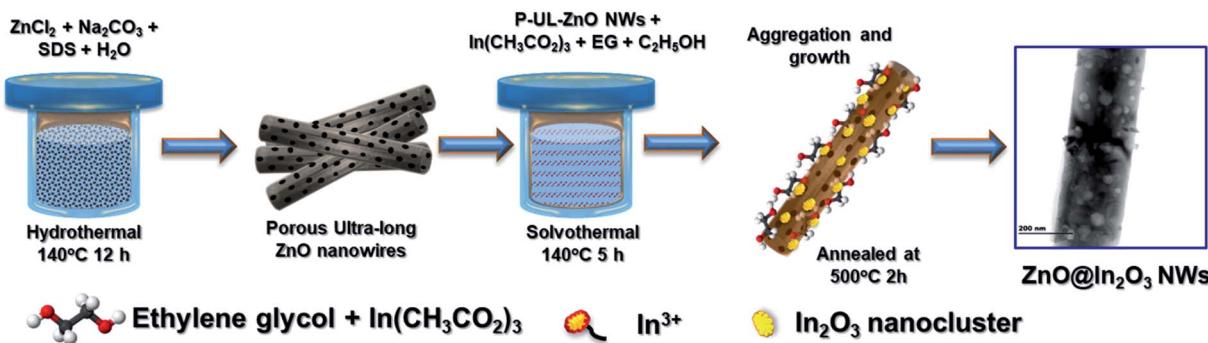
Synthesis of porous $\text{ZnO}/\text{In}_2\text{O}_3$ heterojunction nanowires

Porous ZnO nanowires were chemically synthesized by simple hydrothermal method as per our previous reports.^{32,33} In this investigation, n-n type $\text{ZnO}/\text{In}_2\text{O}_3$ heterojunction nanowires were synthesized by solvothermal process. Briefly, 0.5 mM of $\text{In}(\text{CH}_3\text{COO})_3 \cdot x\text{H}_2\text{O}$ was dissolved in a binary solvent consisting of 1 : 3 fraction of ethylene glycol and ethanol followed by 40 min of vigorous stirring. Meanwhile, the surface treatment of 200 mg of ZnO nanowires was carried out using UV-irradiation (254 nm) for 2 min. The above solution was ultrasonicated for 30 min in order to form a homogenous solution. Further, the solution was subjected to heat treatment at 160 °C for 4 h after shifting to a Teflon-sealed SS autoclave of 100 mL capacity. The resultant product was collected; washed and centrifuged several times with 80% ethanol and deionized water to remove the unwanted In_2O_3 impurities. The product was dried overnight in a hot air oven at 90 °C. The ensuing amorphous precipitate was heat treated for 3 h at 550 °C in air at a ramp rate of 5 °C min⁻¹. After the annealing process, the color of the product turned to light yellow, indicating the crystallization of In_2O_3 nanoislands on the ZnO nanowires.

Results and discussion

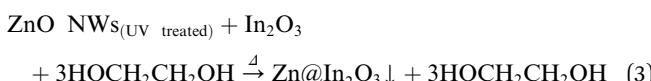
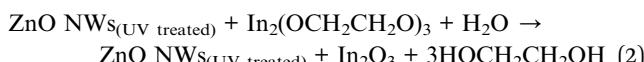
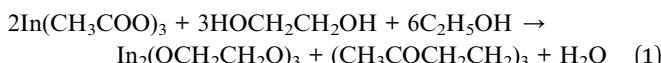
Mesoporous ZnO nanowires were chemically synthesized *via* a simple hydrothermal technique.³⁴ Scheme 1 illustrates the formation mechanism of In_2O_3 nanoislands on ZnO nanowires





Scheme 1 Schematic diagram of the synthesis method adopted for n-n type $\text{ZnO@In}_2\text{O}_3$ heterojunction nanowires.

formed *in situ* using $\text{In}(\text{CH}_3\text{COO})_3$ as the precursor. The chemical reactions during the formation of heterojunction $\text{ZnO@In}_2\text{O}_3$ nanowires can be represented as per eqn (1-3). The purified UV-irradiated ZnO nanowires possess more surface active sites and in the binary solvent of ethanol and ethylene glycol, In^{3+} gets effectively adsorbed over the surface of ZnO nanowires through hydrogen bonding. During the solvothermal hydrolysis process, the In_2O_3 nanoislands were firmly anchored over the surface of ZnO nanowires by initially forming a relatively stable complex (indium ethylene glycolate) due to the strong coordination between indium ions and surface active functional groups of ZnO nanowires. The solvothermal process with the aid of pressure and temperature inevitably induces Ostwald ripening that causes the self-organization of In_2O_3 nanoislands on the surface of ZnO nanowires.³⁵ The resultant mesoporous $\text{ZnO@In}_2\text{O}_3$ heterojunction nanowires were found to be amorphous in nature. The material was further subjected to a high temperature (550 °C) annealing process under oxygen atmosphere in order to improve the crystallinity, and the white powder turned pale yellow.



Structural and morphological characterization of mesoporous $\text{ZnO@In}_2\text{O}_3$ heterojunction nanowires

Fig. 1(a) shows the XRD patterns of thermal treated ZnO nanowires and $\text{ZnO@In}_2\text{O}_3$ heterojunction nanowires. The

highly intense peaks observed at various diffraction angles (2θ) of 32.03°, 34.79°, 36.43°, 47.69°, 56.74°, 63.15°, 68.07° and 69.20° correspond to the crystal planes (100), (002), (101), (110), (103), (200), (112) and (201) of ZnO . The respective peaks matching the hexagonal wurtzite crystal structure of ZnO were indexed (JCPDS card no. 36-1451), with lattice parameters of $a = 3.249 \text{ \AA}$ and $c = 5.206 \text{ \AA}$. The absence of additional peaks clearly confirms the purity of ZnO nanowires. The calculated fraction of intensity among the (101) and (100) planes (I_{100}/I_{101}) of the ZnO nanowires was found to be higher than that of pristine ZnO which evidently reflected in the preferential growth of ZnO nanowires along the $\langle 100 \rangle$ direction. In addition to the ZnO peaks (hexagonal wurtzite structure), the $\text{ZnO@In}_2\text{O}_3$ nanowires also showed peaks at 22.33°, 30.97°, 32.59°, 45.57°, 52.41°, and 72.84° which are attributed to the lattice planes of (012), (104), (110), (024), (116) and (312) of the rhombohedral In_2O_3 crystal structure (JCPDS no. #73-1809), suggesting the formation of heterojunctions.³⁶

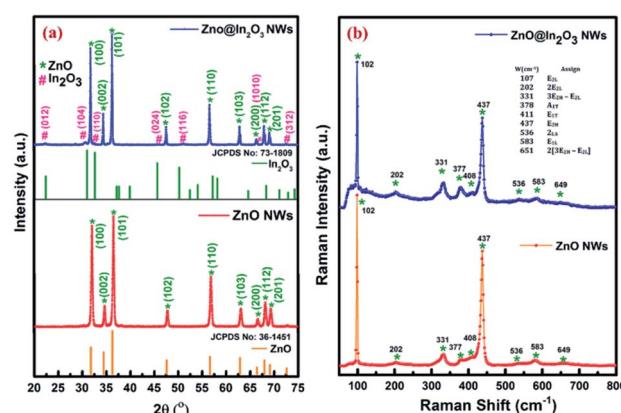


Fig. 1 (a) XRD patterns and (b) Raman spectra of ZnO nanowires and $\text{ZnO@In}_2\text{O}_3$ heterojunction nanowires.



Fig. 1(b) presents the room-temperature Raman peak shifts observed for ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires using the excitation wavelength of a 532 nm laser source in the backscattering mode. The Raman spectral analysis of ZnO nanowires showed an intense peak at 438 cm⁻¹ confirming the hexagonal wurtzite structure, which corresponds to the E₂ high mode of ZnO. Furthermore, the peaks that appeared at the lower frequency range of 329 cm⁻¹ and 378 cm⁻¹ are related to the zone edging phonon vibrations, E₂ high – E₂ low and A₁(TO), respectively.³⁷ A wide peak observed at 583 cm⁻¹ assigned to E₁(LO) confirms the presence of more oxygen vacancies (V_O) and zinc interstitials (Zn_i). The considerable shifts noticed for the ZnO@In₂O₃ heterojunction nanowires could be due to the charge transfer at the interfaces of In₂O₃ nanoislands grown on the ZnO nanowires. The overall peak intensity was found to be suppressed due to the growth pattern of In₂O₃ nanoislands formed over the ZnO nanowires. The peak related to the E₁ (LO) mode of ZnO was suppressed due to the presence of interstitial defects, which acted as favorable sites for the growth of In₂O₃ nanoislands. The peak related to the E₂ (high) mode was found to be wide and weak, same as that observed in the amorphous phase, which might be due to the formation of heterojunctions between Zn–O and In–O bonds. The fading of the A₁(LO) mode at 583 cm⁻¹ is because of the existence of zinc interstitials, oxygen vacancy states, etc.³⁸

The HRTEM images of pristine porous ZnO nanowires and porous ZnO@In₂O₃ heterojunction nanowires are shown in Fig. 2 and S2.[†] The In₂O₃ nanoislands were found to be evenly anchored over the ZnO nanowires with a mean particle size of 12 ± 0.25 nm which confirmed the formation of ZnO–In₂O₃ interfaces (Fig. 2(a)). HRTEM analysis of the hybrid nanowires revealed a well-resolved inter-planar spacing related to ZnO with $d(002) = 2.67 \text{ \AA}$ and In₂O₃ with $d(110) = 2.73 \text{ \AA}$. Though HRTEM of ZnO and In₂O₃ indicated the exposed planes, such as (002) and (110) respectively, it should be noted that the interplanar distance between the (002) plane of ZnO and the (110) plane of In₂O₃ was observed to be matching as depicted in Fig. 2(e–f). Accommodating the lattice strain at the heterojunctions, In₂O₃ nanoislands exhibited an interplanar spacing of 2.91 Å corresponding to the (104) plane anchored on the surface of ZnO nanowires, as observed from Fig. 2(g). From the HRTEM analysis, it is evident that the (002) crystal plane of ZnO and the (110) plane of In₂O₃ are highly exposed to the NO₂ molecules. Further, these facets were simulated via CaRIne crystallography 3.1 to visualize the dangling bonds existing in the respective planes and to estimate the proportions of Zn²⁺ to O²⁻ at the ZnO lattice and In³⁺ to O²⁻ at the In₂O₃ lattice. The SAED pattern of ZnO@In₂O₃ nanowires is shown in Fig. 2(d). The planes (100), (110), (203) and (002) represent the ZnO crystal lattice and the planes (211), (104), (208) and (104) correspond to the In₂O₃ crystal lattice as deduced from the JCPDS card no. 36-1451 for ZnO with the hexagonal wurtzite structure and JCPDS card no. 73-1809 for In₂O₃ with the rhombohedral structure.

These virtual crystal planes were simulated for visualizing the exposed facets along with the dangling bonds and correlated with HRTEM analysis. For the (002) lattice plane terminated with Zn²⁺, the chemisorption capability could be preferred since the

Zn²⁺ ions existing on the (002) plane are able to seize more oxygen from the atmosphere which further responds towards NO₂ molecules through unsaturated oxygen coordination aided by physisorption processes.³⁹ Fig. 2(h) presents the simulated crystal plane after slicing the (002) facet of ZnO, the (104) facet of In₂O₃ and the (110) interface facet of the In₂O₃ crystal structure. From the crystallographic simulation studies, it was evident that the (002) plane possesses only Zn²⁺ on the exposed lattice which can facilitate the adsorption of NO₂ molecules and further entrap the electrons and get reduced. Likewise, the (104) and (110) planes of In₂O₃ terminated with In³⁺ ions on the exposed polar planes are also able to grasp the oxygen from the atmosphere and further aid in physical or chemical adsorption of NO₂ molecules.⁴⁰ The ZnO (002) plane terminated with Zn²⁺ ions and surface anchored In₂O₃ nanoislands forms the heterojunction structure. The In³⁺ terminated planes with the exposed facets of (104) and (110) of In₂O₃ boost the adsorption kinetics of NO₂ molecules at the heterojunctions. Thus, the crystallographic analysis could predict that the superior adsorption of NO₂ could be mainly caused due to the existence of ZnO/In₂O₃ polar surfaces by strong dual interactions between Zn²⁺ and In³⁺ ions on the heterojunctions, which act as a major driving force for the surface reactions during the sensing process.⁴¹ Moreover, the FE-SEM analysis with EDX elemental mapping clearly signified the distribution of Zn, In and O elements on the surface of ZnO as depicted in Fig. 2(i–m), confirming the formation of the ZnO@In₂O₃ heterojunction nanowires.

TEM analysis (Fig. 2(c) and S3[†]) also revealed the presence of mesoporous structures of the ZnO nanowires which was further correlated and confirmed from N₂ adsorption and desorption studies using BET analysis as depicted in Fig. S3.[†] Both porous and non-porous materials exhibited a characteristic type-IV reversible curve associated with the hysteresis loops at partial pressure ranging from 0.0 to 0.9, representing the presence of a mesoporous structure. The specific surface area, pore volume and pore size of bare ZnO, mesoporous ZnO and mesoporous ZnO@In₂O₃ heterojunction nanowires were estimated as tabulated in Table S1.[†] The high surface area illustrates the presence of excess active sites on the surface that could aid in easy charge transfer, which can be reflected in superior gas sensing characteristics of the mesoporous ZnO@In₂O₃ heterojunction nanowires.²⁰

XPS analysis of ZnO@In₂O₃ heterojunction nanowires

The surface characteristics of ZnO@In₂O₃ heterojunction nanowires were further examined by XPS analysis. The survey scan spectrum of the ZnO@In₂O₃ nanowires is depicted in Fig. 3(a). The peaks related to C 1s could originate from the ligands settled during the chemical synthesis and also due to carbon contamination typically found in the survey spectrum. The well-resolved peaks at binding energy values of 1019.8 and 1042.8 eV could be assigned to Zn 2p_{3/2} and Zn 2p_{1/2} respectively, as shown in Fig. 3(b) whereas, Fig. 3(c) presents the high-resolution In 3d state of ZnO@In₂O₃ heterojunction nanowires. For In₂O₃, a couple of peaks located at 442.9 and 450.5 eV is attributed to the binding energies of In 3d_{5/2} and In 3d_{3/2}, respectively. Fig. 3(d) shows broad and asymmetric O 1s profiles deconvoluted into



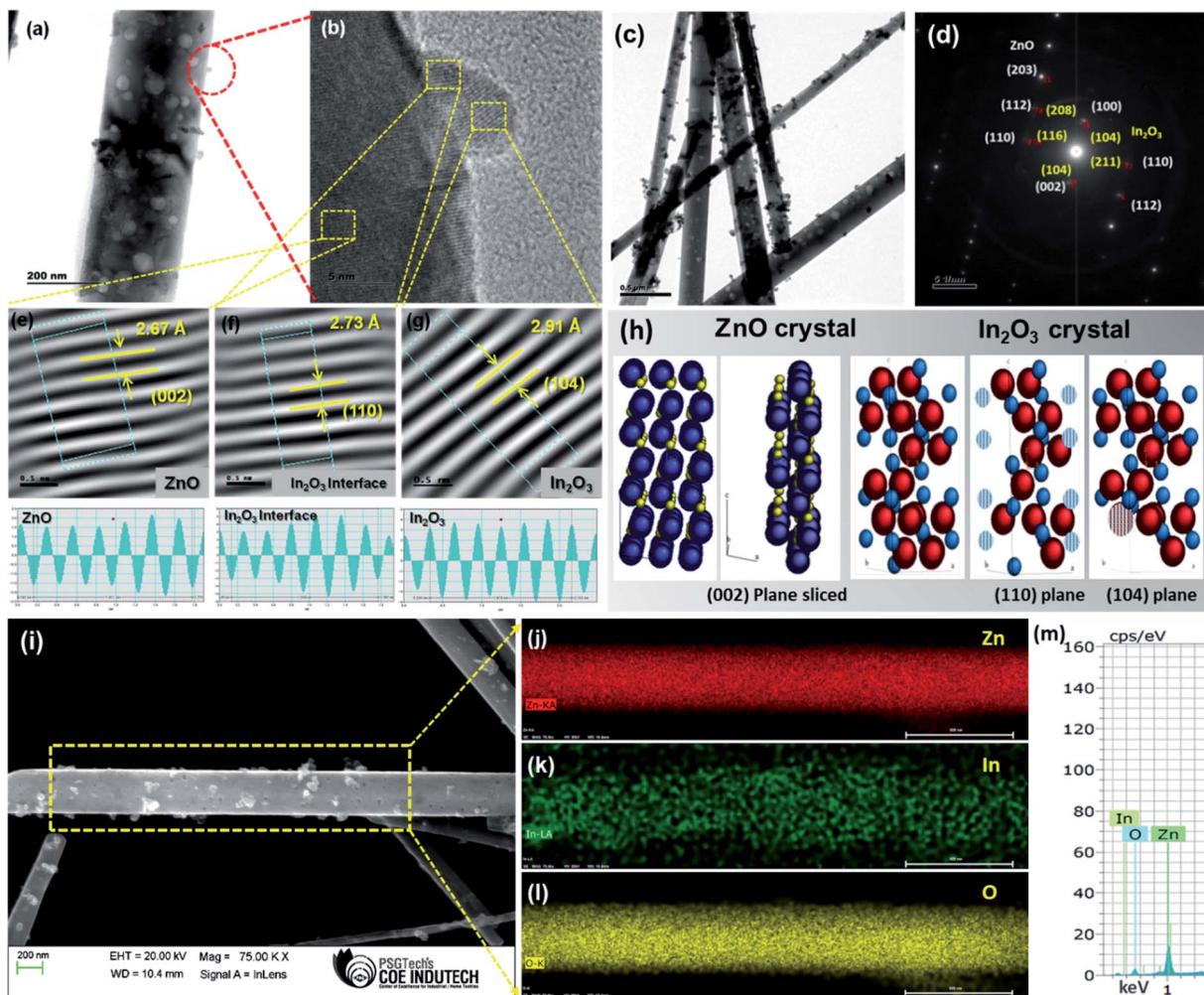


Fig. 2 (a and c) TEM images of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires, (b) HRTEM image of $\text{ZnO}@\text{In}_2\text{O}_3$ nanowires, (d) SAED pattern of $\text{ZnO}@\text{In}_2\text{O}_3$ nanowires, (e–g) the inverse FFT images and estimation of lattice spacing of ZnO , In_2O_3 interface and In_2O_3 nanoisland planes, (h) simulated crystal planes of ZnO and In_2O_3 , (i) FE-SEM image of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires, (j–l) corresponding EDS Elemental maps of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires and (m) the EDX spectrum shows the presence of Zn, In and O elements.

symmetrical peaks sited at 528.5 and 529.64 eV, respectively indicating a pair of oxygen species ionosorbed on the material. The peak at a binding energy of 528.5 eV is supposed to have originated from the lattice oxide, O^{2-} in the ZnO , whereas the adjacent peak residing at the binding energy 529.64 eV is ascribed to ionosorbed O^- on the surface of ZnO nanowires.⁴²

Room-temperature local current–voltage characteristics of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires

Scanning Spreading Resistance Microscopy (SSRM) imaging was employed to map the local charge transport properties of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires at room temperature. Fig. 4(a) shows the topography image of n–n type $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires using contact mode AFM imaging. During contact mode SSRM imaging, a bias voltage of ± 5 V was applied between the conductive tip and the material, as depicted in Fig. 4(b), wherein the resulting current was passed through the tip and sample and was measured in order to

visualize the local spreading resistance. The local electrical conductivity map (Fig. 4(b)) of the n–n type $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires coated on a conductive silicon substrate clearly reveals local electron conduction characteristics across the $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires. The corresponding current–voltage (I – V) curves were obtained from various locations on the surface of heterojunction nanowires. The intention of this particular study was to analyze the local electron transport characteristics of the $\text{ZnO}@\text{In}_2\text{O}_3$ nanowires, in which the conduction in ZnO nanowires (27.6 pA) was found to be comparatively higher compared to that in In_2O_3 nanoislands (22.3 pA) as evident from Fig. 4(c). It can also be emphasized that the material demonstrated good electrical conductivity at room temperature exclusive of any additional heating to move the electrons within the energy bands. Based on the observation from the SSRM imaging and local current–voltage characteristics of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires, it can be ascertained that charge accumulation and depletion can occur at the interface of heterojunctions (Scheme 3(b)) as clearly evident

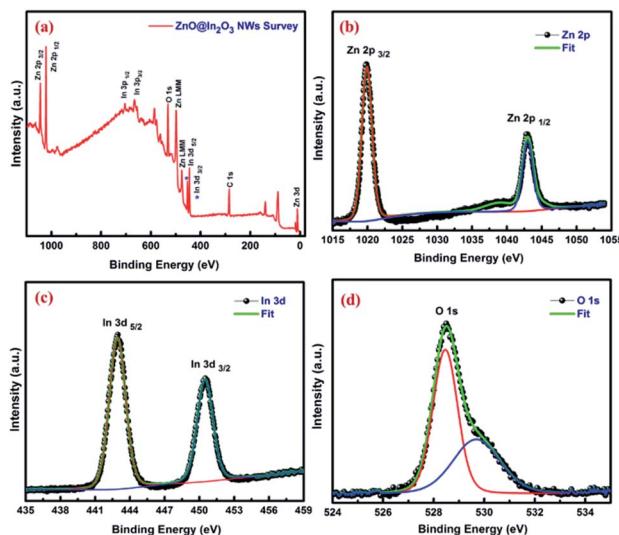


Fig. 3 (a) XPS wide range survey spectrum and high resolution spectra corresponding to (b) Zn 2p (c) In 3d and (d) O 1s of ZnO@In₂O₃ heterojunction nanowires.

from the color contrast across the nanowires.⁴³ This can be directly correlated with individual band structures of the semiconducting heterojunctions. While forming the heterojunction, electrons transfer from a lower work function to higher work function material. Hence, the charge transfer occurs from In₂O₃ to ZnO by which a charge depletion region can be significantly formed at the In₂O₃ junctions implying the electronic upward bending caused by charge recombination at the interface.⁴⁴ In contrast, ZnO (n-type semiconductor) shows higher electron accumulation near to the heterojunction interface, which leads to downward band bending. Therefore, the charge density of ZnO nanowires was found to be higher than that of In₂O₃ nanoislands, which can lead to remarkably superior NO₂ gas sensing properties owing to the distinctive n-n heterojunction hot spots on the surface of ZnO.

Evaluation of the NO₂ sensing performance of ZnO@In₂O₃ heterojunction nanowires

The NO₂ sensing properties of mesoporous ZnO@In₂O₃ heterojunction nanowires were evaluated using an in-house gas

sensor test station.³² In order to estimate the operating temperature, the sensor response (S), $[(R_g - R_a)/R_a]$ upon introduction of 1 ppm of NO₂ gas at different temperatures (RT – 300 °C) was assessed as shown in Fig. 5(a) for porous ZnO nanowires and porous ZnO@In₂O₃ heterojunction nanowires. The enhanced response toward NO₂ was estimated to be at 150 °C and 34 °C for porous ZnO nanowires and porous ZnO@In₂O₃ heterojunction nanowires respectively, which were identified as the working temperatures of these sensing materials. The heterojunction nanowires exhibited a significantly reduced working temperature compared to pristine ZnO nanowires. The observed higher response of ZnO@In₂O₃ heterojunction nanowires under ambient conditions is due to the charge transfer between ZnO and In₂O₃ due to the difference in work functions. Phenomenally, this process leads to charge accumulation and also the depletion region formed at the interfaces of the heterojunction. Hence, the energy desired to reach the highest response will be minimal for heterojunction ZnO@In₂O₃ compared to pristine ZnO nanowires which is responsible for its lower operating temperature.

The dynamic NO₂ response characteristics of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires towards exposure to various concentrations of NO₂ gas at their optimal operating temperature are depicted in Fig. 5(b and c). The increase in resistance was observed when the material was exposed to NO₂, which is the typical n-type behavior of a semiconductor and also ascertained with the porous structure of the nanowires. As the gas concentration was increased, the change in resistance was also found to be simultaneously increased. During the sensing property evaluation, the NO₂ gas was introduced along with (N₂) carrier flow after attaining the stable baseline resistance without any fluctuation. The adsorption of NO₂ gas continued till the saturation was achieved and desorption occurred when NO₂ flow was stopped. The relative response against different concentrations of NO₂ in the range of 500 ppb to 3 ppm was estimated as shown in Fig. 5(d). The NO₂ sensor parameters of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires are summarized in Table S2.† The selectivity of the gas sensor is an important parameter for considering them for real time applications. The responses of interfering gases, such as H₂S, NH₃, SO₂, acetone and ethanol were tested at a constant concentration of 2 ppm under ambient conditions. The ZnO@In₂O₃

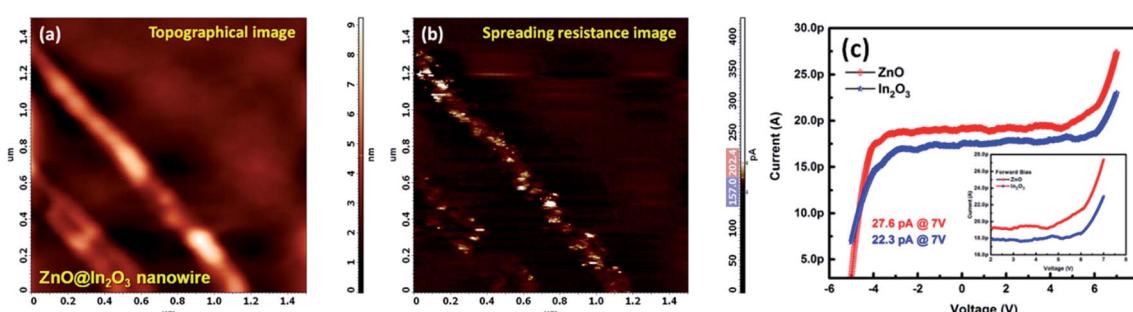


Fig. 4 (a) AFM topography and (b) corresponding SSRM images of ZnO@In₂O₃ heterojunction nanowires, (c) localized I – V characteristics of ZnO and In₂O₃ nanoparticles (inset shows the forward bias I – V curve).

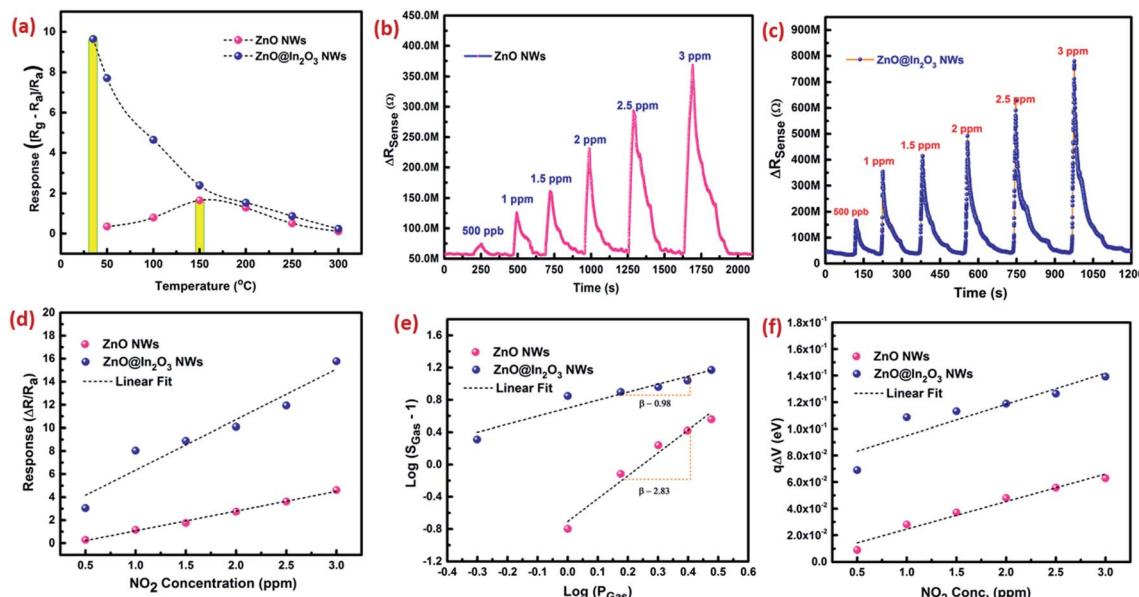


Fig. 5 (a) Response towards exposure to 1 ppm of NO₂ as a function of temperature, (b and c) dynamic NO₂ sensing characteristics, (d) NO₂ response graph, (e) log($S_{\text{Gas}} - 1$) against log P_g plot of curves and (f) variations in the band bending energy graph of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowire based sensors.

heterojunction nanowires exhibited good selectivity towards NO₂ gas at room temperature as evident from Fig. S6† compared to other gases. Hence, NO₂ was chosen as the analyte gas for further studies.

Upon exposure of the heterojunction nanowires towards the NO₂ environment, the NO₂ molecules initially react with negatively charged O²⁻, and O⁻ ions and seize more electrons from the conduction band rather than interacting directly with the surface. This process reduces the electron accumulation region width (L_D) and increases the resistance. Therefore, in order to explore the NO₂ detection mechanism of n-n type ZnO@In₂O₃ heterojunction nanowires, the state of ionosorbed oxygen molecules has to be initially examined. The sensor response of the material and quantity of the analyte could be correlated with,⁴⁵

$$S_g = \left(\frac{R_g}{R_0} \right) = 1 + (P_g \alpha)^\beta \quad (4)$$

$$\log(S_g - 1) = \beta \log(P_g) + \log \alpha \quad (5)$$

where, α is the prefactor and β is the typical exponent for partial pressure dependence and P_g is the analyte concentration. The β value decides the nature of surface oxide species and also elementary reactions that occur on the material surface. If β is equal to 0.5, the surface oxide ions could be O²⁻ also if β is ~ 1 , the surface oxide ions could be O⁻. This could be deduced using the relation log($S_g - 1$) against log(P_g) as shown in Fig. 5(e). As estimated from the slope of the straight line in Fig. 5(e), the β value was calculated to be 2.89 for ZnO nanowires and 1.33 for ZnO@In₂O₃ heterojunction nanowires at room temperature, signifying that the primary surface oxide species present on ZnO@In₂O₃ nanowires are O₂⁻ rather than O⁻ ions.

Moreover, band bending at the heterojunction surface was further estimated based on the sensor response values of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires. According to the Boltzmann distribution law, the density of free electrons (n_s) and band energy ($q\Delta V$) corresponding to the materials can be related as given below;^{46,47}

$$q\Delta V = -K_B \times T \times \ln \left(\frac{R_{\text{air}}}{R_{\text{gas}}} \right) \quad (6)$$

where, K_B is the Boltzmann constant and T is the operating temperature. R_{gas} is the resistance in a NO₂ atmosphere and R_{air} is the resistance in the ambient atmosphere. The band bending can be determined from the sensor response values corresponding to different concentrations of analyte NO₂. The quantification of $q\Delta V$ affirmed that ZnO@In₂O₃ heterojunction nanowires possessed high $q\Delta V$ energy values compared to pristine ZnO nanowires due to the broader depletion region in the presence of NO₂ as deduced from Fig. 5(f). From this analysis it can be inferred that the existence of ZnO/In₂O₃ heterojunction interfaces could be responsible for the preferential electron transport and superior NO₂ adsorption process.

To understand the NO₂ adsorption kinetics, the Elovich equation was used and variation of $(C_{\text{tg}} - C_0)$ versus $\ln(t)$ was plotted with the help of the response/recovery profiles corresponding to exposure to different concentrations of NO₂ as depicted in Fig. S5(a and b).† As per eqn (S1),† the plot between $(C_{\text{tg}} - C_0)$ versus $\ln(t)$ is supposed to be linear.^{48,49} Fig. S5(a and b)† illustrate the adsorption isotherms of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires, which showed an almost linear trend upon exposure to NO₂ gas. The rate of adsorption can be estimated for different ppm levels of NO₂ which followed a linear trend upon increasing



concentration of NO_2 (Fig. S5(c)).[†] The initial adsorption rate was calculated to be $0.93 \Omega^{-1} \text{ s}^{-1}$ at 150°C for ZnO nanowires and $10.76 \Omega^{-1} \text{ s}^{-1}$ at room temperature for $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires towards 1 ppm of NO_2 exposure. Further, reduction in the adsorption rate was noticed upon an increase in the NO_2 concentration owing to continuous cycling of NO_2 . The effect of concentration on NO_2 adsorption kinetics was analyzed, which showed an increase in the potential barrier with respect to the NO_2 concentration. At elevated concentrations, accessibility of NO_2 molecules was higher on the surface of heterojunction nanowires and therefore, the potential barrier increased as depicted in the Fig. S5(d).[†] The interference of humidity in the NO_2 sensing performance of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires was studied as shown in Fig. S7(a and b).[†] The response was found to be relatively constant in the RH (relative humidity) range of 10% to 55%. However, the sensitivity reduced rapidly when the humidity exceeded 60% due to higher RH% interference as moisture adhered on the sensing material restricting the electron transfer between the gas/material interface. The results reveal that $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires have excellent stability at a lower humidity range at room temperature.

Exploration of a plausible NO_2 sensing mechanism by *in situ* SKPM analysis

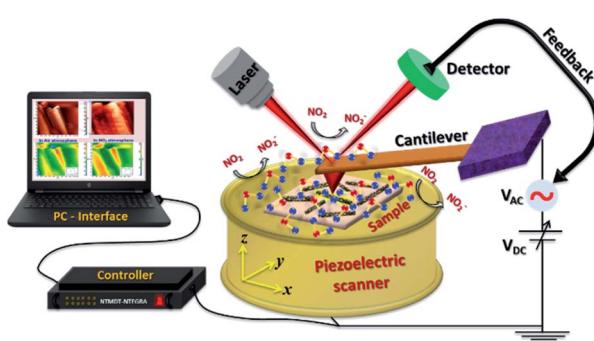
Scanning Kelvin probe microscopy was further implemented to explore the surface potential (SP) variations of the ZnO nanowires and n-n type $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires during exposure to the NO_2 gas environment. By moving the conducting probe towards the material, a biased potential difference is generated owing to the variation in the Fermi energies between the probe and the material.⁵⁰ The local charge transport mechanism during NO_2 gas sensing was further probed by monitoring the surface potential or contact potential difference (CPD) mapping of the n-n type heterojunction nanowires using SKPM during exposure to the NO_2 gas environment as shown in Scheme 2. The work function, (φ) of a MOS is defined as the quantity of energy needed to move an electron present in the surface of the semiconductor material to the

vacuum level.⁵¹ A high surface charge density on the material surface therefore promotes higher φ , allowing the visualization of charge accumulation/depletion on the surface of the material. During SKPM analysis, a tungsten carbide coated silicon nitride probe was allowed to interact electronically with the material surface. The contact potential difference (CPD) was measured from the difference between the Fermi levels of the conducting probe and the material surface.⁵² The work function of the material (φ) was determined from the CPD value with the work function of the SKPM cantilever tip, $\varphi_{(\text{tip})}$. Before proceeding with SKPM measurements on the heterojunction nanowires, the tungsten carbide coated silicon nitride probe was calibrated on a pure Au thin film under similar conditions (Fig. S4†). The contact potential difference of the Au film was measured to be ~ 32 mV. The work function of the conducting probe ($\varphi_{(\text{tip})}$) was initially calibrated as 4.9 eV estimated using the known work function ($\varphi_{(\text{Au})} = 5.1$ eV) of the Au sputtered thin film in order to change the calculated CPD into the work function of the material. Moreover, the contact potential difference is extremely material-dependent and directly associated with the work function of the material and surface dipole moments. In the case of semi-conductors, there can be contributions from charge distribution on the material and surface dipoles and from electronic rearrangements at the material/substrate interface. The difference in the work function of the SKPM probe and the material was calculated using the following equations;

$$\text{CPD} = \frac{\Delta\varphi}{e} = \frac{\varphi_{(\text{tip})} - \varphi_{(\text{sample})}}{e} \quad (7)$$

$$e\text{CPD} = \varphi_{(\text{tip})} - \varphi_{(\text{sample})} \quad (8)$$

where e is the charge, $\varphi_{(\text{tip})}$ is the work function of the conducting probe and $\varphi_{(\text{sample})}$ is the work function of the semiconductor material.⁵³ The topographic AFM images and the corresponding SKPM images of ZnO nanowires and $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires before and during NO_2 exposure are shown in Fig. 6. The CPD before NO_2 exposure was found to be ~ 35 mV and a two fold increase in CPD upto ~ 63 mV was calculated when NO_2 was introduced on ZnO nanowires. The work function (φ) of ZnO nanowires was estimated to be 4.83 eV before NO_2 exposure and the work function increased upto 4.93 eV in the NO_2 environment. Upon exposure to NO_2 gas, electron transfer occurs between adsorbed NO_2 and the surface of nanowires which is mainly due to the active oxygen defects and ionosorbed oxide species. The electron depletion leads to increase in CPD which is evident from the SKPM images depicted in Fig. 6(a-c). The morphology and surface potential distribution mapping using SKPM on $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires before and after exposure to the NO_2 environment are depicted in Fig. 6(d-f). The CPD value of $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires was found to be increased to 103 mV compared to pristine ZnO nanowires (35 mV) in the absence of the NO_2 environment. This enhancement in the CPD value is due to the charge transport between the heterojunction materials



Scheme 2 Schematic representation of *in situ* SKPM imaging performed for $\text{ZnO}@\text{In}_2\text{O}_3$ heterojunction nanowires in the NO_2 gas environment.



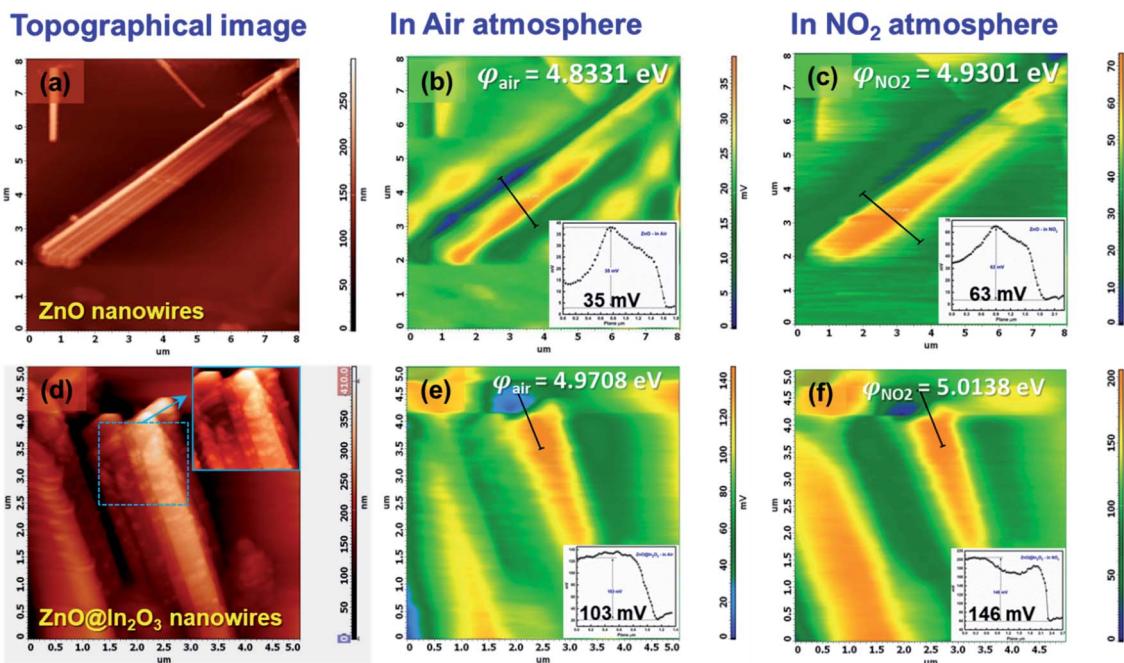


Fig. 6 Representative AFM topographical images of (a) ZnO nanowires and (d) ZnO@In₂O₃ heterojunction nanowires (inset shows the magnified image of heterojunction nanowires), (b and c) SKPM images of ZnO nanowires in air and the NO₂ environment and (e and f) SKPM images of ZnO@In₂O₃ heterojunction nanowires in air and NO₂ environments (inset shows the CPD in air and the NO₂ environment).

(In₂O₃ and ZnO). The electrons in both ZnO nanowires and In₂O₃ nanoislands acquire different work functions and binding energies when they are electrically connected. Typically, the electrons can move from the material with higher Fermi energy to the material with lower Fermi energy since the work function absolutely depends on the Fermi level. Hence, there could be accumulation of charge and also formation of a depletion region at the heterojunction interfaces. The work function of ZnO@In₂O₃ heterojunction nanowires was calculated to be 4.97 eV, which is higher than that of bare ZnO nanowires ($\varphi_{\text{air}} = 4.83$ eV). The increase in the work function indirectly indicates the difference in the Fermi level and surface band bending. The CPD further increased up to 146 mV upon exposure to the NO₂ environment and the corresponding work function was calculated to be 5.02 eV. This enhancement in the CPD value is proportional to the variation in the work function of heterojunction interfaces which can be visualized in the SKPM images as depicted in Fig. 6(d-f). The inset shows the SKPM line scan, denoted by a dark line in Fig. 6(a-c) and (e-f), to measure the CPD before and during NO₂ exposure.

The contact potential difference (eV_{CPD}) between the conducting scanning probe and the material surface corresponds to the variation in their work functions ($\varphi_{\text{tip}} - \varphi_s$).⁵⁴ The work function of the semiconductor materials can be estimated using the relations;

$$\varphi_s = -\chi_s + \Phi_B + (E_C - E_F) \quad (9)$$

$$eV_{\text{CPD}} = \varphi_{\text{tip}} - \chi_s + \Phi_B + (E_C - E_F) \quad (10)$$

where, e is the elementary charge, χ_s is the electron affinity of the sample, Φ_B is the surface band bending, $(E_C - E_F)$ is the difference in the Fermi energy (E_F) also conduction band (E_C) of the material. It is known that the surface potential of the semiconductor materials relies on the surface band bending (Φ_B), the electron affinity (χ_s) and the carrier concentration. The surface band bending (SBB) of ZnO nanowires before and after NO₂ gas exposure using the following equation,

$$\Phi_B = \varphi_M - qV_{\text{CPD}} + \varphi_{\text{off}} - \chi + (E_C - E_F) \quad (11)$$

where, χ is the electron affinity of the ZnO (3.2 eV), φ_{off} is the offset in the estimated work function of the conducting probe found during calibration (~ 32 meV) on the Au film ($\varphi_M = 5.1$ eV) and E_F is the Fermi level related to the conduction band minimum.²⁸ Using eqn (11), the estimated surface band bending (SBB) of ZnO nanowires before NO₂ exposure was 1.92 eV which was increased upto 1.96 eV during NO₂ exposure. Interestingly, the surface band bending for ZnO@In₂O₃ heterojunction nanowires was increased up to 2.04 eV compared to pristine ZnO nanowires. During NO₂ exposure, the SBB value increased further up to 2.1 eV which implied the formation of a vast depletion region in the heterojunction nanowires. Based on Boltzmann approximation, the electron density of the ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires could be estimated, in which the concentration of electrons in n-type semiconductors can be expressed as,

$$n = N_C \exp\left(\frac{E_F - E_C}{K_B T}\right) \quad (12)$$



$$n = N_c \exp \left(\frac{qV_{CPD} - \varphi_{tip} + \chi}{K_B T} \right) \quad (13)$$

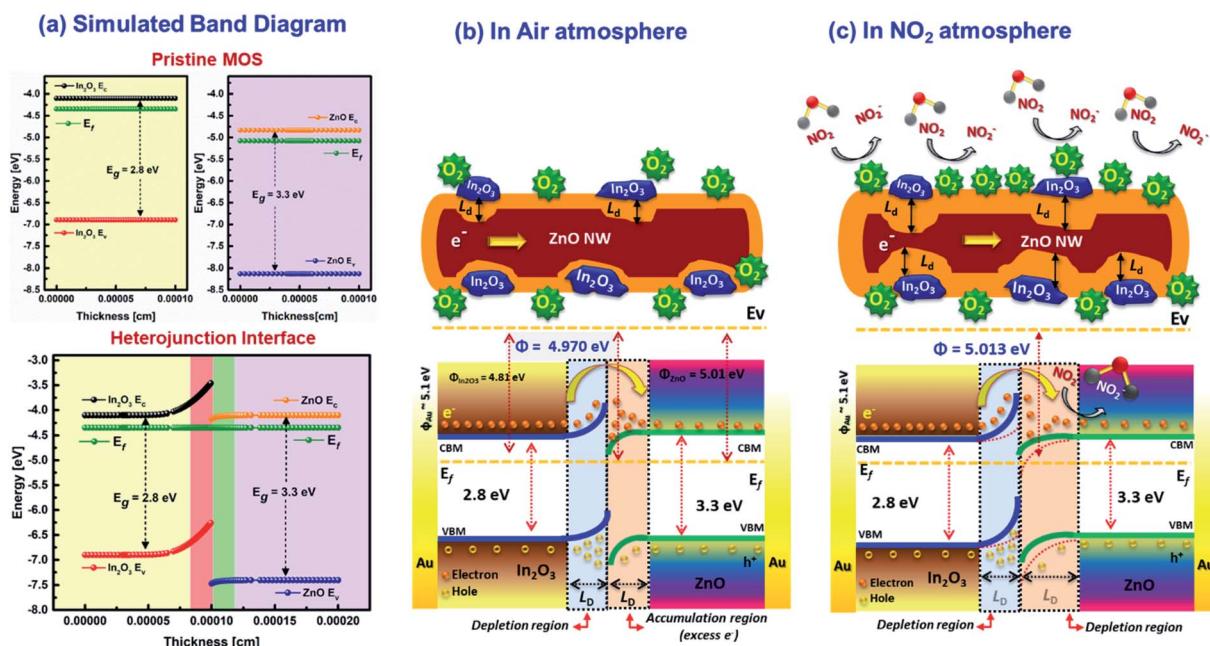
where, E_C and E_F are the conduction band and the Fermi energy level, N_c is the effective density of states, T is the temperature and K_B is the Boltzmann constant.⁵⁴ Here, the work function of Au was ascertained to be 5.1 eV, N_c of ZnO is 3.7×10^{18} , electron affinity of ZnO (χ) is 4.5 eV, the Boltzmann constant, K_B is 8.6×10^{15} eV K⁻¹ and temperature, T is 300 K. The carrier density of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires before and during NO₂ exposure was calculated from SKPM analysis using eqn (13). The carrier density of ZnO@In₂O₃ heterojunction nanowires decreased drastically from 1.18×10^{19} cm⁻² to 0.87×10^{19} cm⁻² during NO₂ exposure. The reduction in charge density clearly states that the charge recombination occurs when the NO₂ molecules are adsorbed on ZnO@In₂O₃ heterojunction nanowires and entrap the electrons present in the conduction band. The space charge region formed due to the SBB at the heterojunction can be described by the depletion width (W) and can be expressed as,²⁸

$$W = \left(\frac{2\Phi_B \epsilon_0}{q^2 N_D} \right)^{1/2} \quad (14)$$

The depletion width (W) formed due to surface band bending and charge carrier density was further calculated from SKPM analysis of ZnO nanowires and ZnO@In₂O₃ heterojunction nanowires using eqn (14) which is summarized in Table S4.[†] The depletion width (W) was found to be increased up to 3.19 nm for heterojunction nanowires compared to pristine ZnO nanowires. During NO₂ exposure, the estimated depletion width was estimated for ZnO nanowires and

ZnO@In₂O₃ heterojunction nanowires to be 3.34 nm and 3.81 nm respectively. The estimated changes in the work function (φ_s), depletion width (W), surface band bending (Φ_B) and carrier density (n_s) values resulting from *in situ* SKPM analysis were further used to deduce the NO₂ sensing mechanism of the ZnO@In₂O₃ heterojunction nanowires. Based on the above experimental evidence, it can be concluded that the variations in the surface potential of the heterojunction nanowires was increased with decreasing electron density upon NO₂ exposure. The electron-hole pair recombination increases due to the increase in carrier density which favors the charge transport between In₂O₃ to ZnO at the heterojunctions.

Based on the evidences from SKPM analysis, the electronic band structure was further theoretically constructed using AFORS-HET v2.5 as shown in Scheme 3(a). The simulated energy band diagram clearly revealed the upward bending state at In₂O₃ and the downward bending state at ZnO interfaces owing to the electron transfer at the heterojunctions due to the difference in their Fermi level energies. The carrier density reaches equilibrium when the Fermi level of the ZnO and In₂O₃ becomes aligned, while forming heterojunctions. The trapping of electrons at the surface states drastically reduced the surface potential properties. While considering the core-ZnO nanowires, the surface could be occupied by more free electrons than pristine ZnO due to the formation of heterojunctions with In₂O₃. This induces a downward bending state and electrons tend to accumulate near the surface of the semiconductor. When electron rich heterojunction nanowires were exposed to NO₂ gas, a majority of carriers tend to be trapped by NO₂ through adsorbed surface oxygen ions (O₂⁻) and the potential barrier of 1D nanowires increased as the carrier density

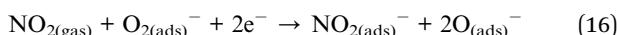


Scheme 3 (a) Simulated energy band diagram before and after contact and schematic diagram showing the NO₂ sensing mechanism (b) in air atmosphere and (c) in the NO₂ gas atmosphere, deduced for ZnO@In₂O₃ heterojunction nanowires.



decreases resulting in increase in both the SBB and depletion width.

Usually when metal oxide materials are exposed to an oxygen atmosphere, various oxide ions molecules like O_2^- , O^- and O^{2-} are adsorbed on the material surface as a function of temperature leading to electron depleted regions on the surface of semiconductor materials.⁵⁵ At lower working temperatures, more O_2^- ions can be adsorbed over the surface of ZnO nanowires. The response of the sensor and rate of adsorption of NO_2 molecules may also depend on the surface adsorbed O_2^- ions. Based on the β value obtained from the NO_2 gas sensing profile, the dominant oxygen species adsorbed over the surface of $ZnO@In_2O_3$ nanowires were found to be O_2^- rather than O^- ions. When the $ZnO@In_2O_3$ nanowires are exposed to NO_2 gas molecules, the molecules electrically react with negatively adsorbed oxygen molecules and further entrap more electrons at the interfaces of the heterojunction as represented by the given equation:



Based on the experimental evidence and theoretical prediction, the energy diagram of n-ZnO/n-In₂O₃ heterojunction nanowires is proposed as illustrated in Scheme 3(b and c). The n-n heterojunctions created between n-type ZnO nanowires and n-type In₂O₃ nanoislands could play a crucial role in tuning the gas sensing performance of the ZnO@In₂O₃ nanowire based sensor. When In₂O₃ and ZnO are hybridized to form the n-n type heterojunction, an interfacial electric field could be formed at the interface between ZnO and In₂O₃. The energy band-gaps of ZnO and In₂O₃ were calculated from UV-DRS experiments as 3.31 and 2.75 eV, respectively. Based on these estimated parameters, the simulated band structure designed for n-ZnO and n-In₂O₃ is shown in Scheme 3(a). The energy band bending state through charge transport, the positions of the conduction and valance bands of n-ZnO/n-In₂O₃ heterojunctions were clearly understood by simulating the energy band structure using the evidence obtained from the SKPM analysis.

Prior to electrical contact, the Fermi energy of ZnO is lower than that of In₂O₃ owing to its lower work function illustrated in Scheme S1.† Once these two dissimilar metal oxides with varied work functions are brought into electrical contact, the electrons move out of from higher Fermi energy (In₂O₃) to lower Fermi energy (ZnO) until the energy levels achieve equilibrium.^{56,57} In the meantime, an interfacial electric charge aligning from core-ZnO to In₂O₃ is formed at the interfaces. Under air atmosphere (Scheme 3(b)), both In₂O₃ nanoislands and ZnO nanowires adsorb negatively charged oxygen ions owing to the oxygen adsorption over the sensor material. As a result of the built-in interfacial electric field, the electrons in the conduction band of In₂O₃ can move to the excited ZnO, and at the same time, holes reside in the valence band of n-In₂O₃. Hence, adsorbed oxygen draw electrons from the semiconductor material, making the n-type In₂O₃ more depleted. This lowered the e-

concentration leads to an upward bending state. Likewise, n-type ZnO become more conductive *i.e.*, an increased e⁻ concentration causing a downward bending state. Similarly, when the n-n heterointerface is in contact, the electrons build up near the ZnO/In₂O₃ junctions forming a depletion region across the In₂O₃ junctions.⁵⁸ During NO_2 exposure which is a strong oxidizing gas, the NO_2 molecules trap e⁻ by interaction with O_2^- ions adsorbed on ZnO and In₂O₃ interfaces by means of electron transport between the heterojunction interfaces of ZnO@In₂O₃ nanowires and NO_2 gas molecules as demonstrated in Scheme 3(c). While NO_2 is a potential oxidizing gas with an excessive electron affinity of 2.28 eV in contrast to 0.43 eV of oxygen. The NO_2 gas reacts with the semiconductor heterojunction material *via* ionosorbed O_2^- species and the potential barrier increases at heterojunction as manifested from *in situ* SSRI and SKPM studies. Furthermore, it was elucidated from the band diagram (Scheme 3(c)) of n-n ZnO@In₂O₃ heterojunction nanowires that a denser depletion region is formed over the surface of ZnO owing to the electron-hole recombination at the heterojunctions than over In₂O₃ upon NO_2 exposure as revealed from the experimental evidence stated in the *in situ* SKPM analysis (Fig. 6(f)). Moreover, the crystallographic defects and enhanced surface area owing to the mesoporous structure of the ZnO@In₂O₃ nanowires provided favourable adsorption facets for a fast response to gaseous NO_2 , which could amplify the gas sensing properties. The gas sensing characteristics of the mesoporous ZnO@In₂O₃ heterojunction nanowire sensor under ambient conditions are therefore considered to be improved by its distinctive morphological and electrical properties.

Conclusions

To conclude, 1-D mesoporous n-n type ZnO@In₂O₃ heterojunction nanowires were effectively synthesized *via* a simple two step hydrothermal method and their local electrical characteristics and NO_2 sensing properties at a reduced operating temperature were thoroughly investigated. Surface-modified In₂O₃ nanoislands on the ZnO nanowires were characterized by various characterization techniques. XRD and HRTEM analyses illustrated the structure of ZnO@In₂O₃ heterojunction nanowires as In₂O₃ nanoislands decorated uniformly over the surface of mesoporous ZnO nanowires. The simulated lattice structure supported by HRTEM analysis was used to presume the NO_2 adsorption on the heterojunction nanowires. The crystallographic analysis was adopted to ascertain the dangling bonds and also estimate the proportion of metals ions to oxygen ions existing at the exposed heterojunction crystal facets. The localized charge transfer process was visualized using spreading resistance imaging, where the maximum electrical conduction occurred at the ZnO sites rather than In₂O₃ due to the electron transfer between the heterojunctions. The enhanced NO_2 sensing performance of the ZnO@In₂O₃ sensor is ascribed to the formation of effective n-In₂O₃/n-ZnO heterojunctions, resulting in a rapid response time (4–6 s) and 10 times superior sensitivity to ZnO nanowires with a detection limit of 500 ppb of NO_2 . Room temperature *in situ* SKPM



analysis under NO_2 exposure showed increment in the work function, band bending and depletion width while forming heterojunctions and revealed the local charge transfer processes in heterojunction nanowires pertaining to the NO_2 sensing process. The boosting of the performance of the sensor was essentially due to Schottky n-n heterojunctions formed at the interfaces of $\text{ZnO-In}_2\text{O}_3$ and also due to the increased carrier concentration and rate of oxygen adsorption. This induced the electron depletion layer leading to enhanced NO_2 gas sensitivity and good selectivity at room temperature. New insights into the sensing mechanism pertaining to n-n type $\text{ZnO@In}_2\text{O}_3$ based heterojunction nanowires revealed during this study can be useful for designing novel n-n type MOS heterojunction materials for the development of high performance NO_2 sensors at a reduced operating temperature for real-time applications.

Conflicts of interest

There are no conflicts to declare.

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